

Form PTO-1449

INFORMATION DISCLOSURE CITATION IN AN APPLICATION

Docket No. : 6573-3 Appl. No. : N/A

Filing Date : Herewith Applicant(s): WAKE et al. Group Art Unit: 2878

U.S. PATENT DOCUMENTS

Ex. Init.	Document No.	Date	Name	Class/ Subclass	Filing Date
M	5,148,022	09/15/1992	Kawaguchi et al		
pr	4,945,239	07/31/1990	Wist et al.		
M	5,636,637	06/10/1997	Guiolet et al.		<u> </u>
M	5,664,574	09/09/1997	Chance		
1/2	4,767,928	09/30/1988	Nelson et al.		
for	4,515,165	05/07/1985	Carroll		
M	5,365,061	11/15/1994	Munoz Elizondo		
1/2	3,973,126	08/03/1976	Redington et al		
M	5,952,664	09/14/1999	Wake et al.		<u>;</u>
m	4,075,883	02/28,1978	Glover		

FOREIGN PATENT DOCUMENTS

Ex. Init.	Document No.	Date	Country	Class/ Subclass	Translation Yes/No
n	EP 0 614 645	30.08.93	EPO		

OTHER DOCUMENTS

	(Includir	ng Author	, Title,	Date,	Pertinent	Pages,	Etc.)
Exam	niner 5d	hn R	, lee	Date	e Considere	ed ///	15/01

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP §609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

Sheet 2 of 2

Form PTO-1449

INFORMATION DISCLOSURE CITATION IN AN APPLICATION Docket No. : 6573-3

Appl. No. : MA 09/8/6/375
Filing Date : Herewith Applicant(s): WAKE et al. Group Art Unit: 2878

U.S. PATENT DOCUMENTS

Ex. Init.	Document No.	Date	Name	Class/ Subclass	Filing Date
R	3,684,889	09/15/1972	Priessnetz et al.		->
M	5,692,511	12/02/1997	Grable	1	>
pr	5,049,741	09/17/1991	Fukuda et al.		
M	5,719,398	02/17/1998	Colak		
7					

FOREIGN PATENT DOCUMENTS

Ex. Init.	Document No.	Date	Country	Class/ Subclass	Translation Yes/No	

OTHER DOCUMENTS

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